Shell ENSIS COMPOUND® DW 1016

Solvent based corrosion inhibitor

Shell ENSIS COMPOUND® DW 1016 is a solvent based rust inhibitor and is intended for use on component parts or finished assemblies and equipment.

Performance Features and Benefits

- Long term protection helps to eliminate rework and keep scrap to a minimum
- Soft waxy film prevents cracking and peeling of protective film
- Low viscosity allows for easy application with dip or spray equipment
- Quick drying time (typically less than an hour) avoids delays in putting parts in storage

Main Applications

- Dip, spray or fogging applications where excellent displacement from water or cleaners is required
- Applications where up to two years of indoor protection or six to nine months outdoor protection is required
- For all applications, this product is used directly from the drum as received. Surface films of this product are readily removed with typical industrial alkaline cleaners or by vapor degreasing. Before use, Shell ENSIS COMPOUND® DW 1016 should be agitated to provide even coatings.

One gallon of Shell ENSIS COMPOUND® DW 1016 will cover approximately 1800-2200 sq. feet with a film thickness of about 1.5 to 2.5 mm.

Advice on applications not covered in this handbook may be obtained from your Shell representative.

Handling and Safety Information

For information on the safe handling, storage, or use of this product, refer to its Material Safety Data Sheet at http://www.epc.shell.com/. If you are a Shell Distributor, please call 1+800-332-6457 for all of your service needs. All other customers please call 1+800-237-8645 for all of your service needs.

Protect the Environment

Do not discharge into drains, soil, or water.

Typical Physical Characteristics

Shell ENSIS COMPOUND® DW 1016	Test Method	
Appearance	Visual	Dark brown liquid
Film Characteristics		Soft, waxy film
Flash Point, °F	D 92	170
Density, lbs/gal		6.78

These characteristics are typical of current production. While future production will conform to Shell specifications, variation in these characteristics may occur.